

What Is Claimed Is:

1. A liquid crystal display device comprising:
- a first electrode on a first substrate having a plurality of slit patterns;
- a second electrode on a second substrate;
- a liquid crystal layer between the first and second substrates, the liquid crystal layer having different alignment directions by each slit pattern; and
- at least one light-shielding layer below the first electrode.
2. The device as claimed in claim 1, wherein the light-shielding layer is located below a middle portion of the first electrode.
3. The device as claimed in claim 1, wherein the light-shielding layer is located below each slit pattern.

4. The device as claimed in claim 1, wherein the light-shielding layer is located below both the first electrode and the slit patterns.

5. The device as claimed in claim 1, wherein the first electrode includes a transparent conductive material.

6. The device as claimed in claim 1, wherein the second electrode includes a transparent conductive material.

7. The device as claimed in claim 1, further comprising an insulating film on an entire surface of the first substrate.

8. A method of fabricating a liquid crystal display device on first and second substrates, comprising:

forming at least one light-shielding layer on the first substrate;

forming a first electrode having a plurality of slit patterns over the light-shielding layer including the first substrate;

forming a second electrode on the second substrate;
assembling the first and second substrates; and
forming a liquid crystal layer having different
alignment directions by each slit pattern between the first and
second substrates.

9. The method as claimed in claim 8, wherein the light-
shielding layer is formed below a middle portion of the first
electrode.

10. The method as claimed in claim 8, wherein the light-
shielding layer is formed below each slit pattern.

11. The method as claimed in claim 8, wherein the light-
shielding layer is formed below middle portions of both the first
electrode and the slit patterns.

12. The method as claimed in claim 8, wherein the first
electrode includes a transparent conductive material.

13. The method as claimed in claim 8, wherein the second electrode includes a transparent conductive material.

14. The method as claimed in claim 8, further comprising forming an insulating film on an entire surface of the first substrate and the light-shielding layer.

095979-09200
"6265560"